

LISTING SHOWING THE AMENDMENT TO THE CLAIMS

This listing replaces all prior listings of claims.

IN THE CLAIMS

Amend the claims as follows:

1 (Currently amended). An electronic component made from primarily organic material, comprising:

[[a]] an electrically insulating substrate and/or lower layer having a depression formed by a laser; and

at least one electrical conductor track and/or electrode in the depression, the depression having steep walls, sharp contours and a relatively rough bottom surface, the at least one conductor track and/or electrode comprising at least one electrically conductive material for interconnecting electrical components on the substrate .

2 (Previously presented). The electronic component as claimed in claim 1, having at least two conductor tracks and at least two electrically conductive electrodes and a distance l smaller than $10\text{ }\mu\text{m}$ between the two conductor tracks, the at least two electrodes and/or between a conductor track and an electrode.

3 (Previously presented). The electronic component as claimed in claim 1 wherein the conductor track and/or electrode comprises at least one metallic layer or metal alloy layer.

4 (Previously presented). The electronic component as claimed in claim 1 wherein at least one layer of the conductor track is organic material.

5 (Currently amended). A method for producing an organic electronic component with a conductor track or electrode, the component having [[a]] an insulating lower layer and/or a substrate, the method comprising treating the lower layer and/or substrate with a laser such that at least one depression and/or one modified region are formed in the lower layer and/or the substrate, then filling the depression and/or modified region with an electrically conductive material to thereby produce the conductor track and/or electrode from the electrically conductive material for interconnecting electrical components.

6 (Previously presented). The method as claimed in claim 6, including the step of mechanically structuring the electrically conductive material.

7 (Previously presented). The method as claimed in claim 5 in which superfluous electrically conductive material is produced, the method including wiping off the superfluous conductive material in a process step following the application of the layer.

8 (Previously presented). The method as claimed in claim 6 Including forming the at least one depression and/or one modified region with a pulsed laser.

9 (Previously presented). The method as claimed in claim 6 which is carried out in a continuous roll-to-roll process.

10 (Previously presented). The method as claimed in claim 5 wherein the electrically conductive material is metallic.